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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/667,006	09/21/2000	Young W. Kwon	2658-0222P	8776

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BIRCH STEWART KOLASCH & BIRCH LLP  
P O Box 747  
Falls Church, VA 22040-0747

EXAMINER
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DUONG, THOI V

ART UNIT	PAPER NUMBER
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2871

DATE MAILED: 05/23/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

**Office Action Summary**

Application No.

09/667,006

Applicant(s)

KWON ET AL.

Examiner

Thoi V Duong

Art Unit

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-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

**Period for Reply**

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 03 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).
- Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

**Status**

- 1) ☒ Responsive to communication(s) filed on 28 February 2003.
- 2a) ☒ This action is **FINAL**.                      2b) ☐ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

**Disposition of Claims**

- 4) ☒ Claim(s) 1-22 is/are pending in the application.
- 4a) Of the above claim(s) \_\_\_\_\_ is/are withdrawn from consideration.
- 5) ☐ Claim(s) \_\_\_\_\_ is/are allowed.
- 6) ☒ Claim(s) 1-22 is/are rejected.
- 7) ☐ Claim(s) \_\_\_\_\_ is/are objected to.
- 8) ☐ Claim(s) \_\_\_\_\_ are subject to restriction and/or election requirement.

**Application Papers**

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☐ The drawing(s) filed on \_\_\_\_\_ is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.
- Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
- 11) ☐ The proposed drawing correction filed on \_\_\_\_\_ is: a) ☐ approved b) ☐ disapproved by the Examiner.
- If approved, corrected drawings are required in reply to this Office action.
- 12) ☐ The oath or declaration is objected to by the Examiner.

**Priority under 35 U.S.C. §§ 119 and 120**

- 13) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☐ All b) ☐ Some \* c) ☐ None of:
1. ☐ Certified copies of the priority documents have been received.
  2. ☐ Certified copies of the priority documents have been received in Application No. \_\_\_\_\_.
  3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).
- \* See the attached detailed Office action for a list of the certified copies not received.
- 14) ☐ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).
- a) ☐ The translation of the foreign language provisional application has been received.
- 15) ☐ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.

**Attachment(s)**

- 1) ☒ Notice of References Cited (PTO-892)                      4) ☐ Interview Summary (PTO-413) Paper No(s). \_\_\_\_\_
- 2) ☐ Notice of Draftsperson's Patent Drawing Review (PTO-948)                      5) ☐ Notice of Informal Patent Application (PTO-152)
- 3) ☐ Information Disclosure Statement(s) (PTO-1449) Paper No(s) \_\_\_\_\_                      6) ☐ Other: \_\_\_\_\_

### DETAILED ACTION

1. This office action is in response to the Amendment, Paper No. 5, filed February 28, 2003.

Accordingly, claims 1, 10 and 22 were amended. Currently, claims 1-22 are pending in this application.

#### ***Claim Rejections - 35 USC § 102***

2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

(e) the invention was described in-

(1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effect under this subsection of a national application published under section 122(b) only if the international application designating the United States was published under Article 21(2)(a) of such treaty in the English language; or  
(2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that a patent shall not be deemed filed in the United States for the purposes of this subsection based on the filing of an international application filed under the treaty defined in section 351(a).

3. Claims 1 and 3-6 are rejected under 35 U.S.C. 102(e) as being anticipated by Nakashima et al. (USPN 6,141,123).

As shown in Figs 12A-12D, Nakashiwa discloses a method for fabricating a hologram diffuser which comprises:

providing a substrate 219;  
forming a resin layer 210 on the substrate; and  
forming a hologram pattern in the resin layer,  
wherein forming the hologram pattern includes:

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locating an original hologram plate 213 at an upper portion of the resin layer;  
pressing to form a hologram pattern in the resin layer (col. 16, lines 45-50);

hardening the resin, wherein the resin layer is made from a thermal hardening resin, and further including the step of curing the resin layer by applying heat; and wherein the resin layer is made from an ultraviolet hardening resin, and further including the step of curing the resin layer by applying ultraviolet light (col. 18, lines 26-31); and

removing the original hologram plate (col. 18, lines 19-25).

Nakashima also discloses that the patterned resin layer is preferably provided with either or both anti-reflection means and polarizing means on either or both the front and back sides (col. 22, line 65 through col. 23, line 3). Accordingly, these means smooth the surface of the hologram pattern and activate light beam diffusion at the hologram pattern.

Nakashima finally discloses that the resin layer formed of polycarbonate (col. 4, lines 36-39) is coated on the substrate (col. 15, lines 59-65) and has a thickness of 10 micrometers (col. 16, lines 24-26).

### ***Claim Rejections - 35 USC § 103***

4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

5. Claims 7-9 are rejected under 35 U.S.C. 103(a) as being unpatentable over Nakashima et al. (USPN 6,141,123) in view of Ohtaki et al. (USPN 6,432,498 B1).

Nakashima discloses a method for fabricating a hologram diffuser that is basically the same as that recited in claims 7-9 except for the thickness of the smoothing layer as well as its refractive index compared to the refractive index of the resin layer. As shown in Fig. 13, Ohtaki discloses a method for fabricating a hologram diffuser 41 comprising a hologram layer 41, a hot-melt adhesive layer 42 and a smoothing layer 43 having a thickness of 2 micrometers to 200 micrometers (col. 32, lines 30-41) and formed of polypropylene for improving the storage stability of the hologram diffuser under increased temperature or pressure (col. 25, lines 52-62). As known in the art, the refractive index of polycarbonate is 1.586 and that of polypropylene is 1.48. Accordingly, the smoothing layer formed of polypropylene has a refractive index difference of greater than 0.1 compared to the refractive index of the resin layer formed of polycarbonate.

Thus, it would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the method for fabricating a hologram diffuser with the teaching of Ohtaki by forming a smoothing layer having a proper thickness so as to prevent the hologram from deformation by external force.

Finally, with respect to claim 7, as known in the art, spin coating, knife coating or extrusion coating may be used for forming the resin layer on the substrate.

6. Claims 2, 10, 12, 14 and 17-22 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shirochi (USPN 6,075,581) in view of Nakashima et al. (USPN 6,141,123).

As shown in Fig. 11, Shirochi discloses a liquid crystal display (LCD) comprising:

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a lower polarizer 24,  
a lower substrate 22 arranged at an upper portion of the lower polarizer,  
switching devices arranged in a matrix on the substrate (col. 18, lines 54-59);  
a liquid crystal layer 21 provided at an upper portion of the lower substrate;  
a color filter layer 18 formed on the liquid crystal layer (col. 18, lines 60-65);  
an upper substrate 52 arranged on the color filter;  
an upper polarizer 25 arranged above the upper substrate;  
a diffuser 51 arranged between the upper substrate and the upper polarizer for  
diffusing light (col. 19, lines 22-28); and  
a back light unit 12 disposed below the lower polarizer.

Shirochi discloses a LCD that is basically the same as that recited in claims 2, 10, 12, 14 and 17-22 except that the diffuser is not a hologram diffuser. As shown in Fig. 13, Nakashima discloses a hologram layer 201 comprising a resin selected from a thermal hardening resin and an ultraviolet hardening resin (col. 8, lines 53-67), and a smoothing layer provided at the upper portion of the hologram layer, wherein the smoothing layer smoothes a surface of hologram layer and activates light beam diffusion at the hologram layer (col. 22, line 65 through col. 23, lines 3),

wherein the hologram layer is formed of polycarbonate (col. 4, lines 36-39),  
diffuses light (col. 1, lines 6-11) and has a thickness of 10 micrometers (col. 16, lines 24-26); and

wherein a shape of the hologram layer pattern controls a range of visual angle (col. 1, lines 6-11).

Thus, it would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the LCD of Shirochi with the teaching of Nakashima by employing a hologram diffuser arranged between the color filter and the upper substrate so as to obtain a wide range of visual angle for the display.

7. Claims 11 and 13 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shirochi (USPN 6,075,581) in view of Nakashima et al. (USPN 6,141,123) as applied to claims 2, 10, 12, 14 and 17-22 above and further in view of Ohtaki et al. (USPN 6,432,498 B1).

The LCD of Shirochi as modified in view of Nakashima includes all that is recited in claims 11 and 13 except for the thickness of the smoothing layer as well as its refractive index compared to the refractive index of the resin layer. As shown in Fig. 13, Ohtaki discloses a method for fabricating a hologram diffuser 41 comprising a hologram layer 41, a hot-melt adhesive layer 42 and a smoothing layer 43 having a thickness of 2 micrometers to 200 micrometers (col. 32, lines 30-41) and formed of polypropylene for improving the storage stability of the hologram diffuser under increased temperature or pressure (col. 25, lines 52-62). As known in the art, the refractive index of polycarbonate is 1.586 and that of polypropylene is 1.48. Accordingly, the smoothing layer formed of polypropylene has a refractive index difference of greater than 0.1 compared to the refractive index of the resin layer formed of polycarbonate. Thus, it would have been obvious to one having ordinary skill in the art at the time the invention was made to further modify the method for fabricating a hologram diffuser with the teaching of Ohtaki

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by forming a smoothing layer having a proper thickness so as to prevent the hologram from deformation by external force.

8 Claims 15 and 16 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shirochi (USPN 6,075,581) in view of Nakashima et al. (USPN 6,141,123) as applied to claims 2, 10, 12, 14 and 17-22 above and further in view of Abileah et al. (USPN 5,629,784).

The LCD of Shirochi as modified in view of Nakashima includes all that is recited in claims 15 and 16 except for a twisted nematic liquid crystal display and the upper and lower polarizers are crossed perpendicular to each other. As shown in Fig. 3, Abileah discloses a twisted nematic liquid crystal display comprising a nematic liquid crystal 9 disposed between an upper polarizer 15 and a lower polarizer 3, wherein the transmission axes of the upper polarizer and the lower polarizer are crossed perpendicular to each other for rendering normally white display (col. 8, line 56 through col. 9, line 2). Thus, it would have been obvious to one having ordinary skill in the art at the time the invention was made to further modify the LCD of Shirochi with the teaching of Abileah by employing a twisted nematic LCD having the upper polarizer and the lower polarizer crossed perpendicular to each other so as to obtain a normally white display.

### ***Conclusion***

9. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP



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§ 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

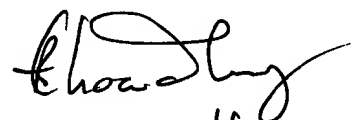
A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

10. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Thoi V. Duong whose telephone number is (703) 308-3171. The examiner can normally be reached on Monday-Friday from 8:00 am to 4:30 pm. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Robert Kim, can be reached at (703) 305-3492.

Thoi Duong



05/10/2003



T. Choudhury  
Primary Examiner